IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: NOZAKI, et al.

1 6 1998 Sefial No.: 09/015,287

Group Art Unit: Not yet assigned

Examiner: Not yet assigned

filed: January 29, 1998

POLYMER COMPOUND FOR A CHEMICAL AMPLIFICATION RESIST AND A FABRICATION PROCESS OF A SEMICONDUCTOR DEVICE

USING SUCH A CHEMICAL AMPLIFICATION RESIST

INFORMATION DISCLOSURE STATEMENT PURSUANT TO 37 CFR 1.97(b)

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

For:

The attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached Form PTO-1449. One copy of each of these documents is attached.

No fee or certification is required in connection with this Information Disclosure Statement, since it is being submitted prior to the issuance of a first official action on the merits in the above-captioned application.

The above information is presented so that the Patent and Trademark Office can, in the first instance, determine any materiality thereof to the claimed invention. See 37 CFR 1.104(a) and 1.106(b) concerning the PTO duty to consider and use any such information. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the documents cited in the attached Form PTO-1449 be made of record therein and appear on the first page of any patent to issue therefrom.

The Commissioner is authorized to charge our Deposit Account No. 01-2340 for any fee which is deemed by the Patent and Trademark Office to be required to effect consideration of this statement.

Respectfully submitted,

ARMSTRONG, WESTERMAN, HATTORI,

McLELAND & NAUGHTON)

Luke A. Kilyk Attorney for Applicants Reg. No. 33,251

Atty. Docket No. 980055 1725 K Street, N.W., Suite 1000 Washington, DC 20006

Tel: (202) 659-2930 Fax: (202) 887-0357

LAK/lnf

Enclosures: PTO-1449 and 9 references